### Plasmons in Metallic Nanostructures: Excitation, Propagation and Detection

Simon Dickreuter, Julia Gleixner, Andreas Ganser, Andreas Kolloch, Daniel Benner, Tobias Geldhauser, Markus Schmotz, Johannes Boneberg, Elke Scheer, Paul Leiderer

University of Konstanz



#### Outline

- Introduction
- Localized plasmon modes in gold nanoparticles

imaged by

- local ablation of a substrate
- local melting of the structures
- two-photon photopolymerization
- Propagating plasmon modes in thin mesoscopic gold stripes on Silicon membranes, imaged by
  - plasmon-phonon conversion
  - plasmon-photon conversion
- Conclusions

#### **Optical Antenna**



Fig. 1. Atomic force microscope images (a and b) and dark field scattering spectra (c) of a single gold bowtie optical nanoantenna with feedgap of 35 nm (black line) and 5 nm (red line).

triangle edge length 128nm, thickness 32nm

#### Merlein et al., Nature Photonics 2, 230 (2008)

## Electronic Transport Through Atomic-Size Contacts



D. Guhr et al., Phys. Rev. Lett. 99, 086801 (2007)



## Light-induced Conductance Change

Scanning the focus across the break junction (Au)



Interpretation: at 648nm plasmons are excited in the leads, which propagate into the contact area

#### Outline

- Introduction
- Localized plasmon modes in gold nanostructures

imaged by

- local ablation of a substrate
- local melting of the structures
- two-photon photopolymerization
- Propagating plasmon modes in thin mesoscopic gold stripes on Silicon membranes, imaged by
  - plasmon-phonon conversion
  - plasmon-photon conversion
- Conclusions



#### Near-field Distribution of Au Triangles



film thickness 40nm, substrate: glass or Si

#### **Optical Near-fields of Metal Nanostructures**

Au on Si: "near-field photography" (with 150fs laser pulse, 800nm)



P.L., C. Bartels et al., Appl. Phys. Lett. 85, 5372 (2004)

### **Comparison with FDTD Simulations**

(Finite Difference in the Time Domain)

500nm Au structures on Si, irradiated with 800nm fs laser pulse



Ablation experiment for gold triangles with 40 nm Au thickness on Silicon

Simulated electric-field of gold triangles with 40 nm Au thickness on Silicon (+ 4 nm natural oxide-layer)

quadrupole mode!

 $\Rightarrow$  good agreement in the near field distribution between simulations and experiment

(if one takes into account details of the structure and the substrate, like the curvature of the "triangles" and the SiO<sub>2</sub> surface layer)

## Optical Nearfield Enhancement: Quantitative Determination by Local Ablation



## Optical Nearfield Enhancement: Quantitative Determination by Local Ablation

Depth of ablated hole

- by ablation using the near field enhancement Lochtiefe [nm] at the triangle tip  $\frac{0}{120}$ lokale Fluenz [mJ/cm<sup>2</sup>] - by ablation using a ablatiertes Volumen [µm<sup>3</sup>] focussed laser beam Lochtiefe [nm] in the far field (focus 30µm) Enhancement factor ~ 11 (quadrupole mode) Maximalfluenz [J/cm<sup>2</sup>]

#### Effect of ps Pulses?

#### Au triangles on Si

after irradiation with ps laser pulse



A. Kolloch et al., Appl. Phys. A (2011)

#### Optical Nearfield Enhancement: Quantitative Determination

Simulation for locally dissipated energy (amplification compared to a smooth gold film))



## Optical Nearfield Enhancement: Quantitative Determination by Local Melting



polarization  $\leftrightarrow$ 

1µm

#### Optical Near Field Enhancement determined by local melting



Melting threshold for triangle tips: 60 mJ/cm<sup>2</sup> Melting threshold of the unstructured gold film: 550 mJ/cm<sup>2</sup>

 $\Rightarrow$  amplification factor ~ 9

#### Near Field Imaging by Two-Photon Polymerization using the nonlinear intensity dependence of SU8 polymerization for 800nm light



2-Photon Polymerization for different polarizations (indicated by the arrows)

Experiment





FDTD calculation



(scale bars 100 nm)

**Dipole mode**  $\Rightarrow$  **amplification factor** ~ 600±140

T. Geldhauser et al., Plasmonics 6, 207 (2011); Langmuir 28, 9041 (2012)

#### Outline

- Introduction
- Localized plasmon modes in gold nanostructures

imaged by

- local ablation of a substrate
- local melting of the structures
- two-photon photopolymerization
- Propagating plasmon modes in thin mesoscopic gold stripes on Silicon membranes, imaged by
  - plasmon-phonon conversion
  - plasmon-photon conversion
  - Conclusions

#### **Propagating Surface Plasmon Polariton**



# Excitation of Surface Plasmons with Photons

Problem: matching the wave vectors of plasmon and photon (excitation on a smooth metal surface is not possible)



coupling via prism (Kretschmann configuration)



coupling via grating

#### Gold Structure on Thin Si Membrane

Si: 340nm thick Au: 40nm Design: MCBJ



#### Grating for Plasmon Excitation

generated with Focussed Ion Beam



#### **Optical Set-up**



#### Spectral Transmissivity of Si Membranes

340nm thick



#### Temperature Dependence of the Optical Transmissivity



#### **Temperature Map**

of a membrane which is heated in the centre by a focussed laser beam



#### Plasmon propagation along strip? Influence of the constriction?



Insert: Simulation by Golaleh Ghafoori

# Heating the Grating with a focussed laser beam

polarization horizontal

calculated absorption: 19%

polarization vertical



calculated absorption 11%

 $\Rightarrow$  coupling is strongly enhanced by the grating





Scattered light in optical microscope



#### Indium Particles on a Si Membrane, heated by a 1000µs laser pulse

(example for a time-resolved measurement



Sequence taken at time intervals of 200µs

#### **Time-resolved Measurements**

Light polarization horizontal (i.e. parallel to grating bars)



#### **Time-resolved Measurements**

Light polarization horizontal (i.e. parallel to grating bars)



temperature map at t=1.5µs

#### **Comparison with Simulation**



Crosses: experiment (laser pulse width 2µs) Lines: simulation using COMSOL Multiphysics (heat source defined by a simulation using Lumerical FDTD)

#### Conclusions

- Plasmon resonances in metallic nanostructures can lead to strong (local) enhancement of the electromagnetic field
- The optical near field distribution can be imaged by various techniques, e.g.
  - local ablation of proper substrates (e.g. smooth Si wafers)
  - local melting
  - 2-photon polymerization
  - ...
- The enhancement can be localized to  $d << \lambda_{light}$
- Good agreement with FDTD calculations has been obtained
  - for the spatial distributions
  - enhancement factors? (under investigation)
  - Plasmonic effects on conductivity, nanostructuring, nanomelting, spin-plasmonic devices ...

Si membranes are efficient thermometers: high temporal and spatial resolution

## Thanks to ...

#### Department of Physics, University of Konstanz:

Johannes Boneberg Anton Plech **Christof Bartels** Hans-Joachim Münzer Juliane König-Birk Mario Mosbacher Tobias Geldhauser Andreas Kolloch **Daniel Benner** Paul Kühler Philipp Leiprecht Julia Gleixner Simon Dickreuter Andreas Ganser

Groups of Prof. Dekorsy, Leitenstorfer and Scheer

#### Instituto de Optica, CSIC, Madrid Carmen Afonso Jan Siegel Javier Solis Theory: Javier Garcia de Abajo

#### RIES, Hokkaido University, Sapporo

Hiroaki Misawa Tobias Geldhauser Kosei Ueno Saulius Joudkazis (now Swinburne Univ., Melbourne)

## ... and thank you!